

# X-ray Free Electron Laser (XFEL)

## Part-1: Accelerator

Sept. 14, 2015

Takahiro Inagaki

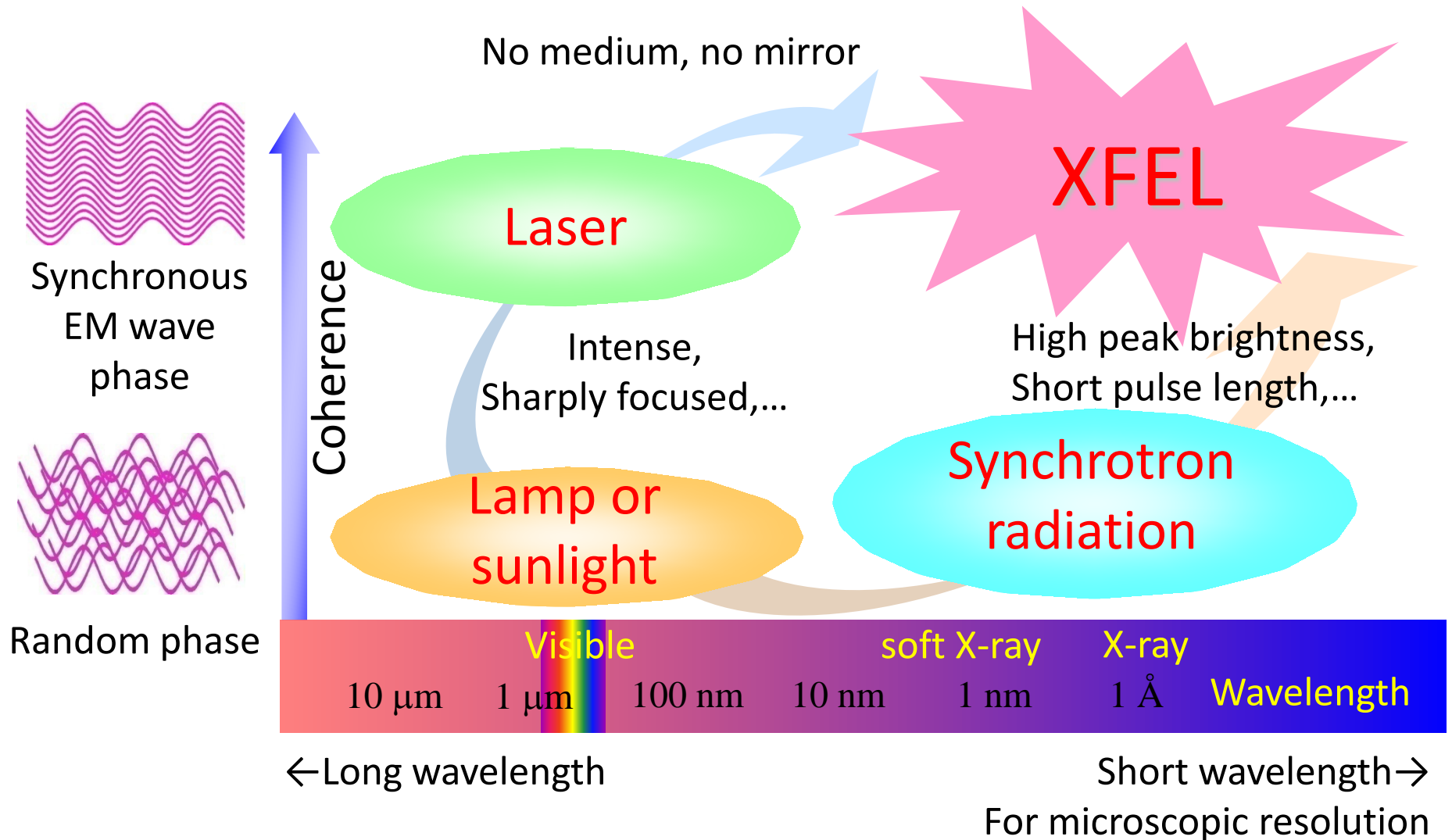
RIKEN SPring-8 center

XFEL research & development division

# Outline

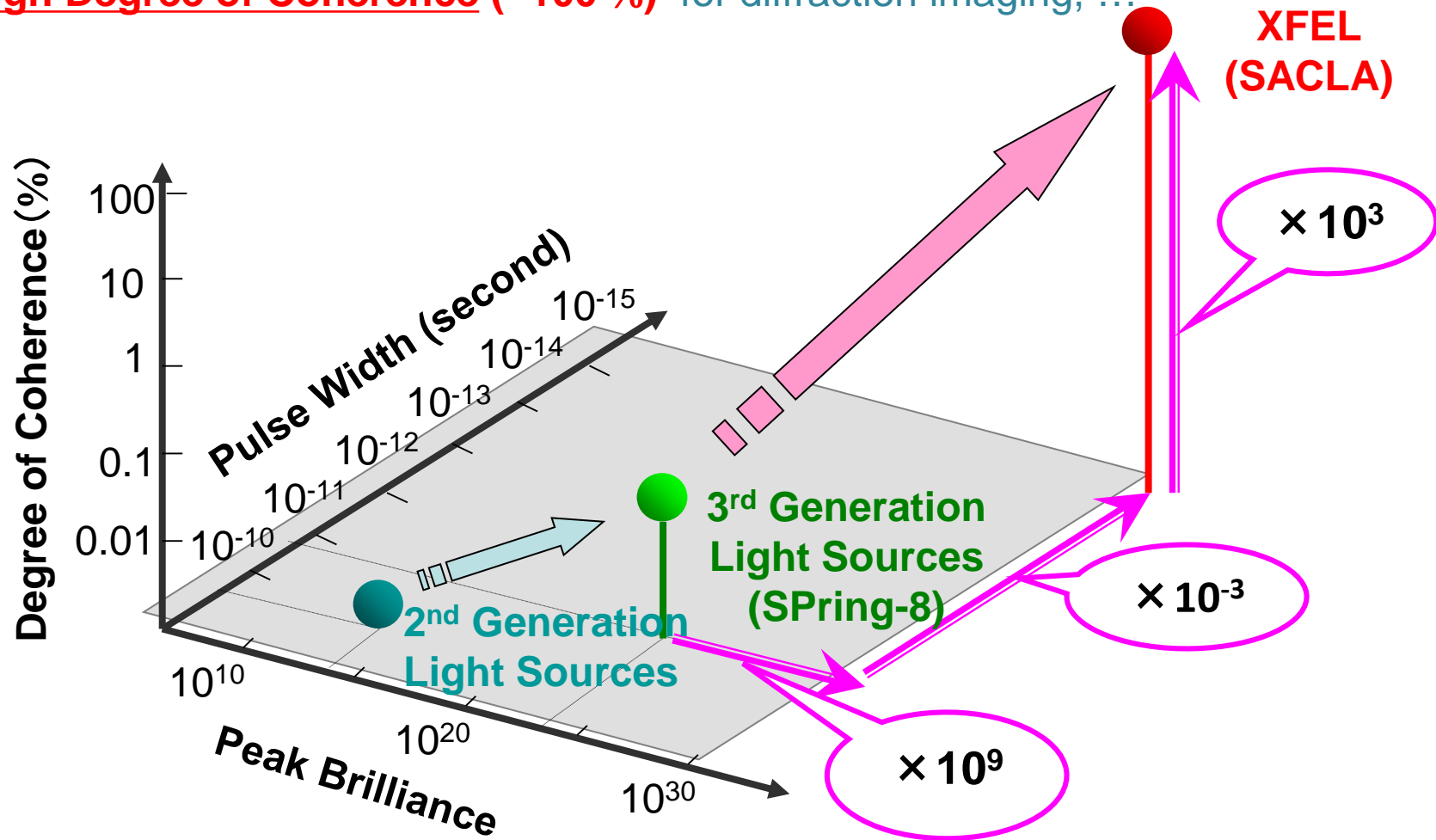
- **Introduction**
- FEL mechanism
- SACLA machine configuration
- Present status and outlook
- Summary

# What is X-ray Free Electron Laser (XFEL)?



# Remarkable features of XFEL

- **High Peak Brilliance** ( $\sim 10^{33}$ ) for physics in extremely intense field, ...
- **Narrow Pulse Width** ( $\sim 10$  fs) for ultrafast reaction or interaction, ...
- **High Degree of Coherence** ( $\sim 100$  %) for diffraction imaging, ...

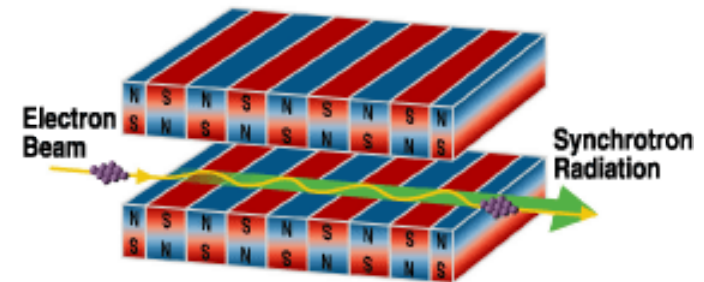
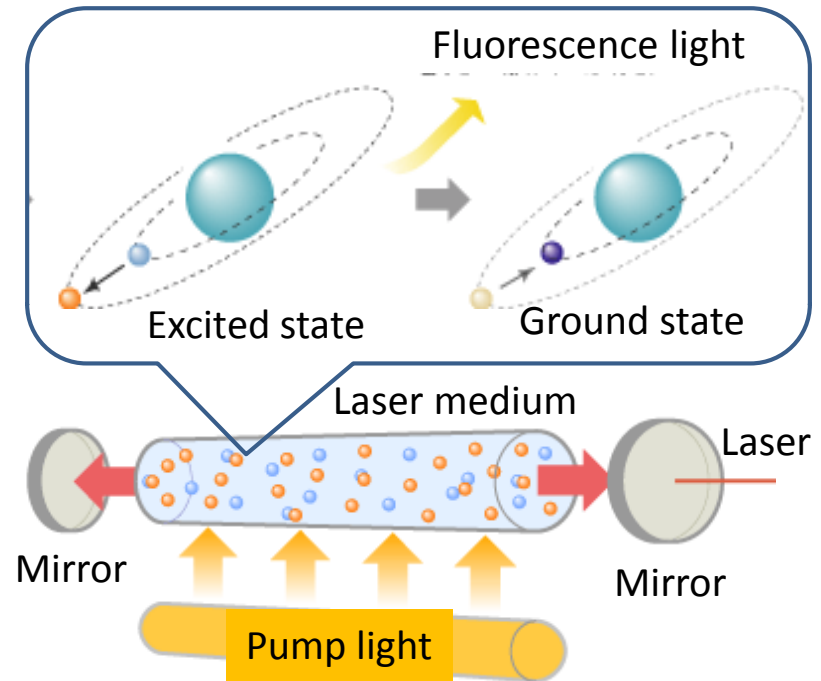


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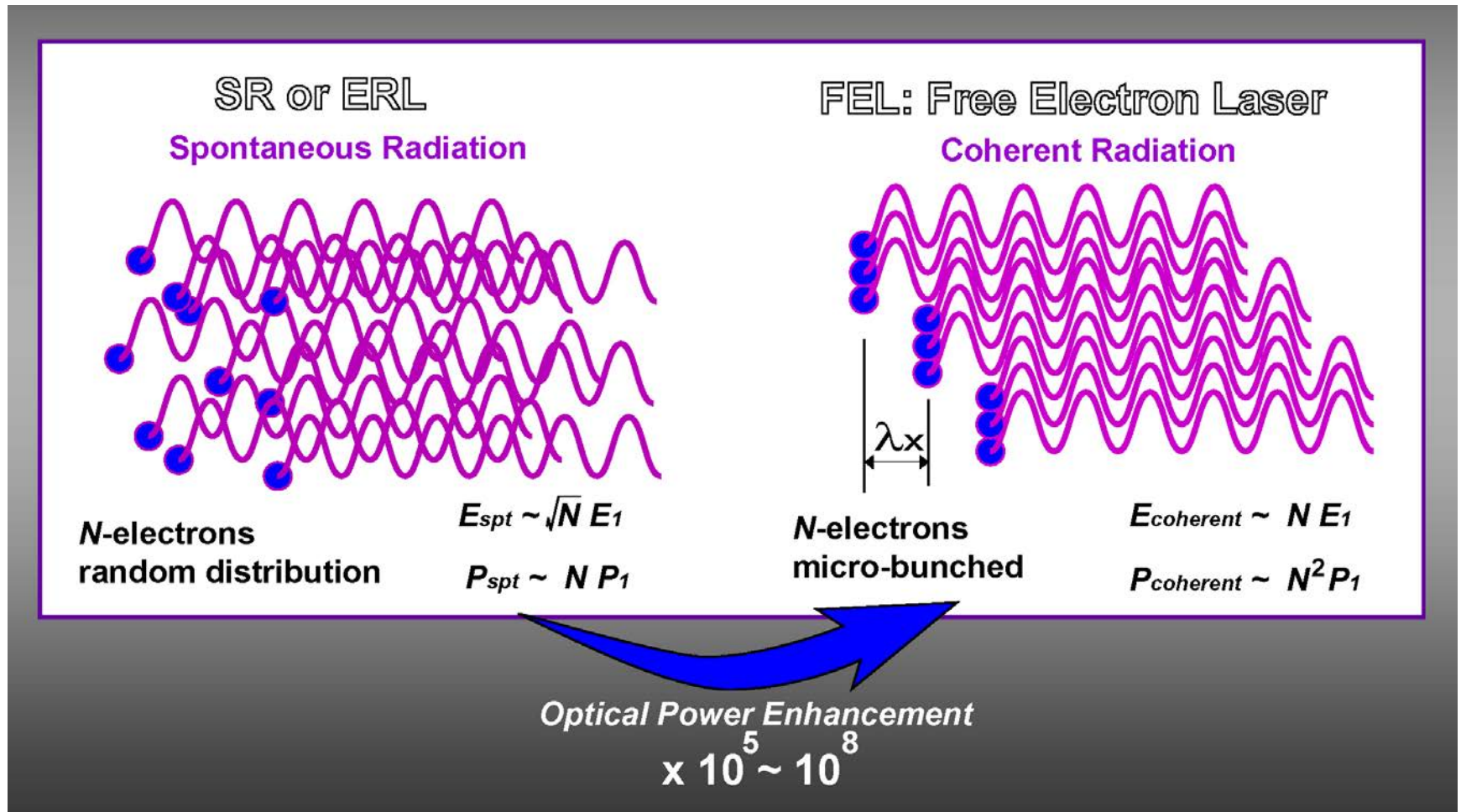
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# Laser amplification mechanism

- Visible light laser
  - Stimulated photon emission in the laser medium.
  - Amplified by the optical cavity.
- X-ray
  - Almost transmit the materials.
  - Low interaction to laser medium.
  - No available reflection mirror.
- Free electron laser (FEL)
  - Stimulated synchrotron radiation from the electron beam (free electron) in the undulator.

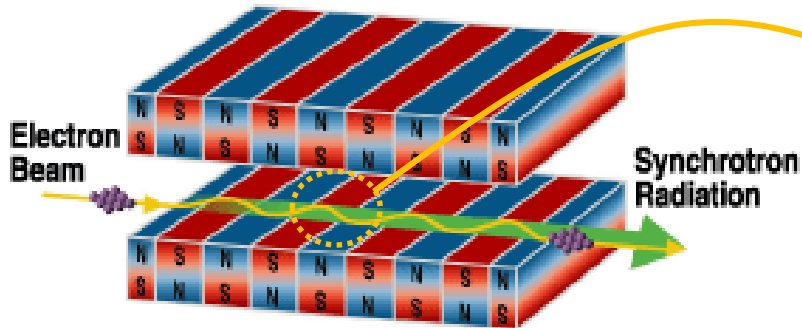


# Micro-bunched electron enhances the radiation power

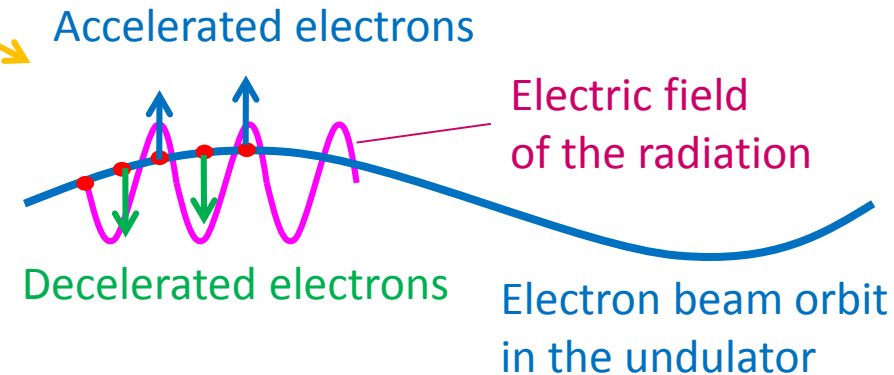


# How to make micro bunch in the undulator

Electrons emit undulator radiation



Electron's energies are periodically modulated by EM field of the radiation



Photon wavelength:

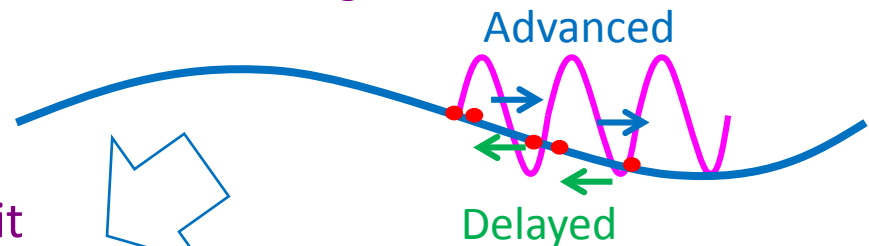
$$\lambda_x = \lambda_u / 2\gamma^2 * (1 + K^2/2)$$

↑  
Magnet period

↑  
Electron beam energy

↑  
Magnetic field strength

Electrons are gathered (micro-bunch) in the wavelength intervals



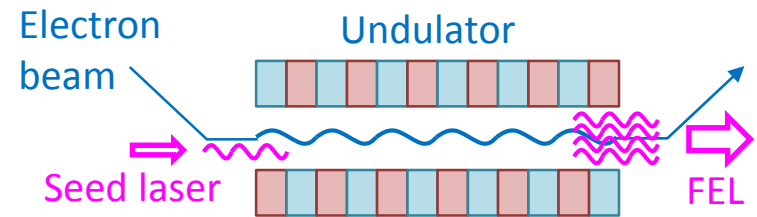
Micro-bunched electrons emit  
Intense, coherent radiation (laser)

# Various type of Free Electron Lasers

- **Seeded FEL**

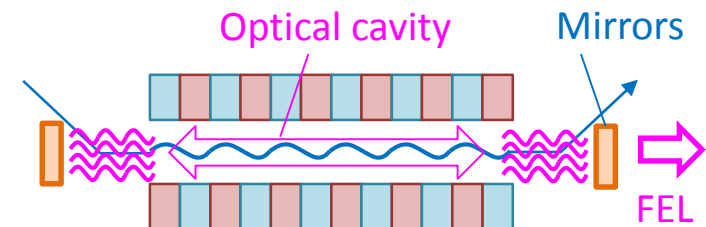
- External laser gives initial modulation.
- Wavelength range is limited by seed laser.
- 61 nm @SCSS/SPring-8 in 2010.

(T. Togashi et al. Opt. Express, 2011)



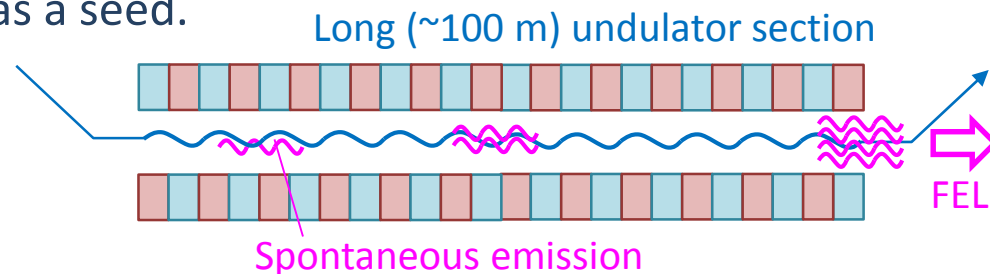
- **Cavity FEL**

- Long electron pulse length ( $> \text{several } \mu\text{s}$ ).
- Wavelength range is limited by mirror.
- Popular for infrared (THz) FELs.

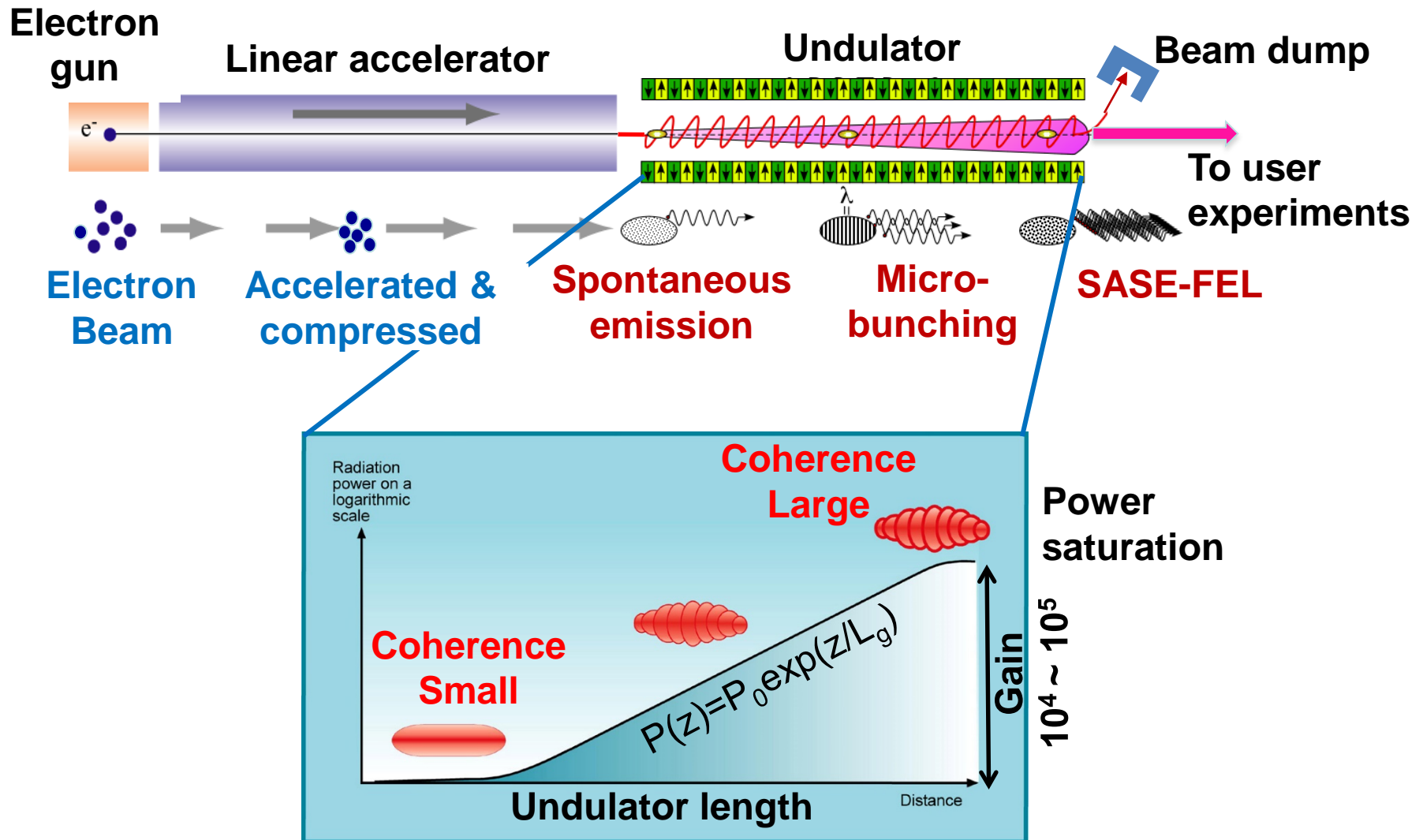


- **Self Amplified Spontaneous Emission (SASE) FEL**

- Spontaneous emission works as a seed.
- No limitation for wavelength.
- Intrinsic fluctuation due to initial spontaneous emission.



# SASE-type XFEL schematic



# SASE-XFEL, basic formulas (for linear undulator)

## Typical parameters at SACLA

- Photon wavelength:  $\lambda_x = \frac{\lambda_u}{2\gamma^2} \cdot \left(1 + \frac{K^2}{2}\right)$ 
  - Beam energy:  $\gamma \equiv E_e/(m_e c^2)$
  - Undulator period:  $\lambda_u$

←X-ray 0.12 nm  
←High 8 GeV  
←Short 18 mm
- FEL parameter:  $\rho \propto \left(\gamma I_e \cdot \frac{\lambda_x^2}{\sigma_x \cdot \sigma_y} \cdot f(K)\right)^{1/3}$ 
  - Beam current:  $I_e$
  - Beam size:  $\sigma_x, \sigma_y$
  - Undulator parameter:  $K \equiv (eB\lambda_u)/(2\pi m_e c)$

←High typ.  $5 \times 10^{-4}$   
←High several ~10 kA  
←Small typ. 30  $\mu\text{m}$   
←High 2.1
- Gain length (1D approx.):  $L_g = \frac{\lambda_u}{4\pi\sqrt{3}\rho}$ 

←Short typ. 2 m
- Radiation power growth:  $P_x(z) \propto \exp\left[\frac{z}{L_g} \left(1 - \frac{(\Delta\gamma/\gamma)^2}{12\rho^2}\right)\right]$ 
  - Energy spread:  $\Delta\gamma/\gamma$

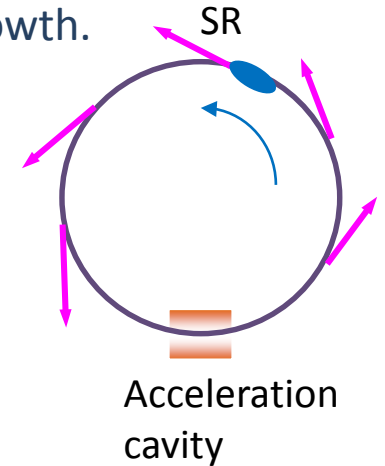
←Small  $<10^{-3}$
- Saturation power:  $P_{sat} \sim \rho P_{beam} = \rho N_e E_e$ 

←High typ. 500  $\mu\text{J}$

# XFEL requires high-dense, low-emittance electron beam

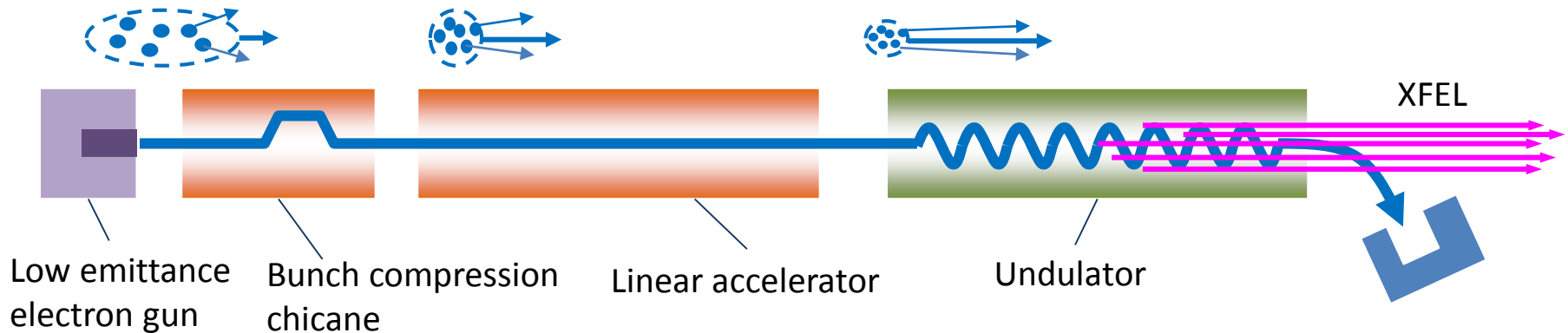
- Ring type accelerator

- Synchrotron radiation causes energy spread and emittance growth.
- Unable to obtain enough quality beam for XFEL.



- Linear accelerator

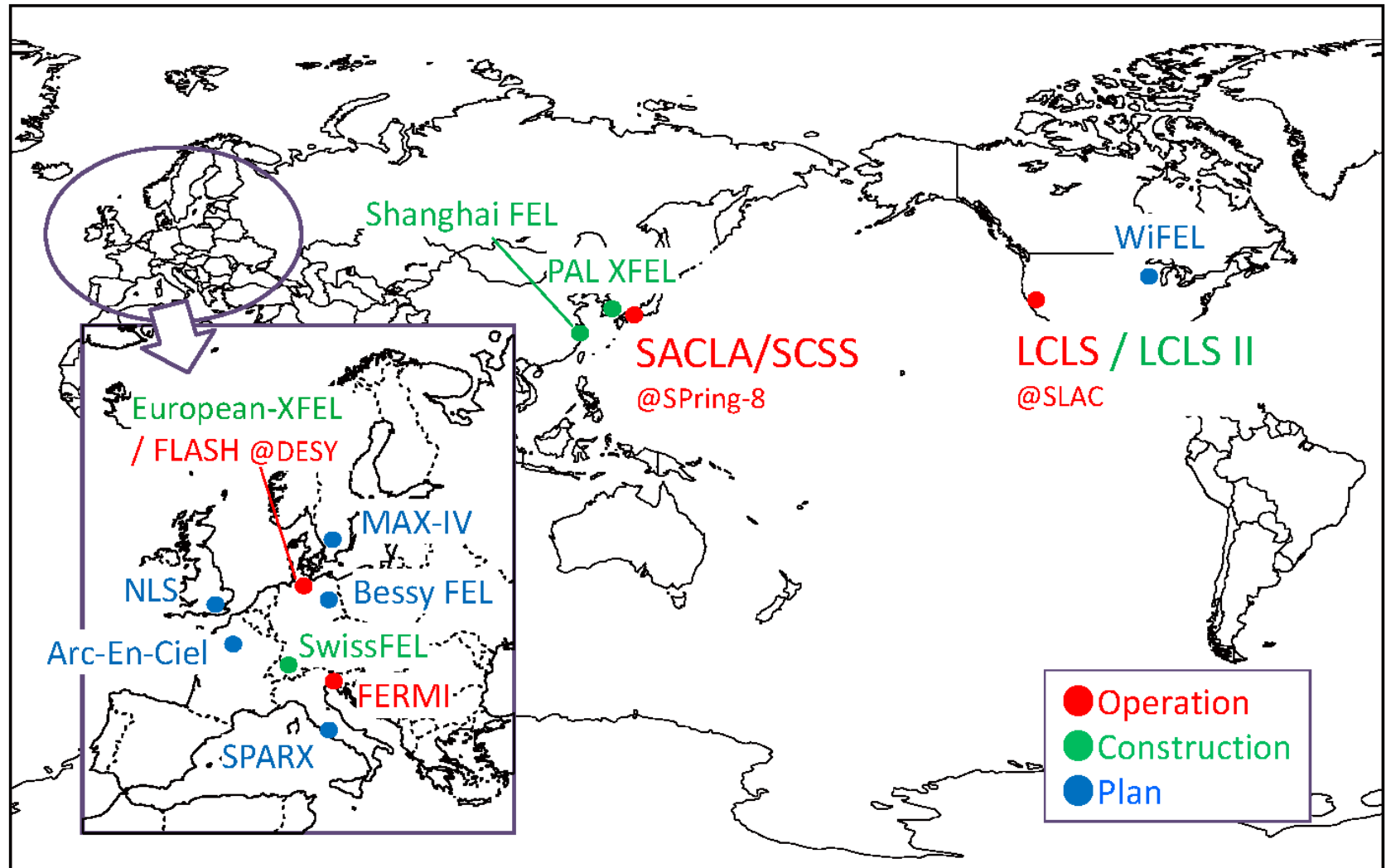
- Low emittance (beam size x divergence) electron gun.
- Transverse beam size is focused by the beam acceleration.
- Bunch length compression to several kA.






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- FEL mechanism
- **SACLA machine configuration**
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# Short wavelength FEL facility in the world ( $\lambda_x < 100$ nm)



# Comparison of three XFELs

Facility	<b>LCLS</b>	<b>SACLA</b>	<b>European-XFEL</b>
Place	SLAC, USA	SPring-8, Japan	DESY, Germany
Length	2 km	<b>0.7 km</b>	3.5 km
E-gun	RF gun	Thermionic gun	RF gun
Accelerator	Normal cond. (S-band)	Normal cond. (C-band)	<b>Super cond.</b> (L-band)
Undulator	Out-vacuum	In-vacuum	Out-vacuum
Energy	14 GeV	<b>8 GeV</b>	17.5 GeV
Wavelength	> 0.15 nm	> 0.06 nm	> 0.05 nm
Const. cost	75 G-yen	<b>37 G-yen</b>	150 G-yen
Operation	<b>2009~</b>	2011~	2017 ?
	<b>First XFEL</b>	<b>Compact, low-cost</b>	<b>Long pulse, multi bunch</b>
			

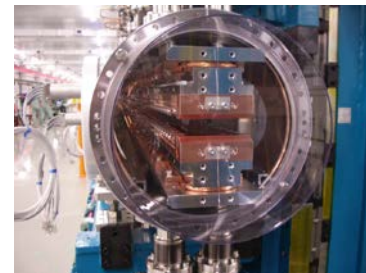
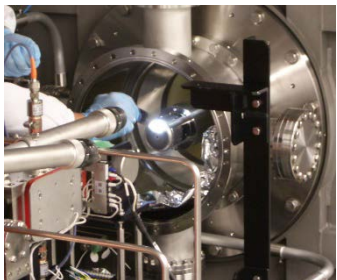
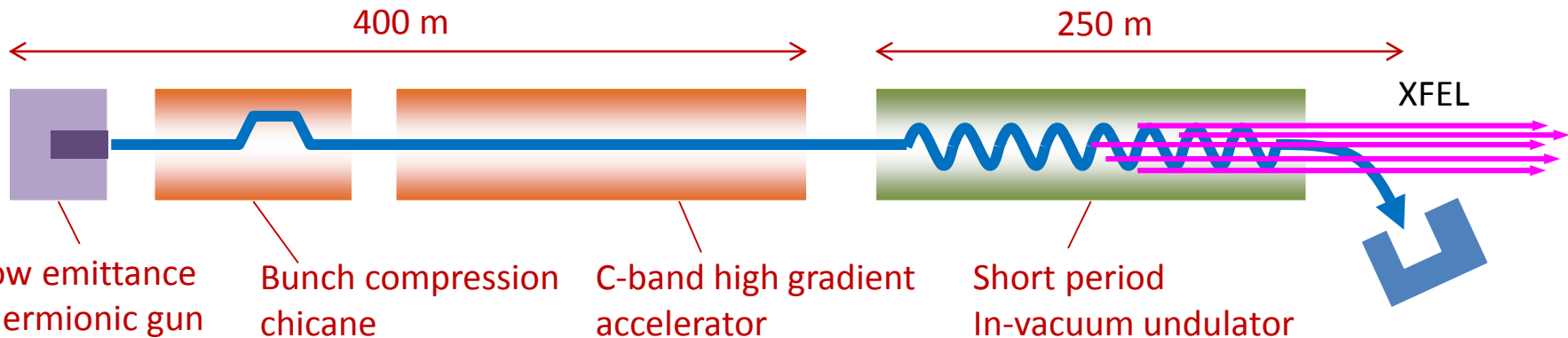
# Concept of compact XFEL “SACLA” (Spring-8 Angstrom Compact X-ray Free Electron Laser)

- Short period undulator → Lower beam energy  
 $\lambda_u = 18 \text{ mm}$
- High gradient accelerator → Short accelerator length  
 $E_{acc} = 35 \sim 40 \text{ MV/m}$
- Low emittance e-gun ( $\epsilon_N < 1\pi \mu\text{rad}$ ) +  
bunch compression → Short saturation length

$$\lambda_x = \frac{\lambda_u}{2\gamma^2} \cdot \left(1 + \frac{K^2}{2}\right)$$

$$\rho \propto \left( \gamma I_e \cdot \frac{\lambda_x^2}{\sigma_x \cdot \sigma_y} \cdot f(K) \right)^{1/3}$$

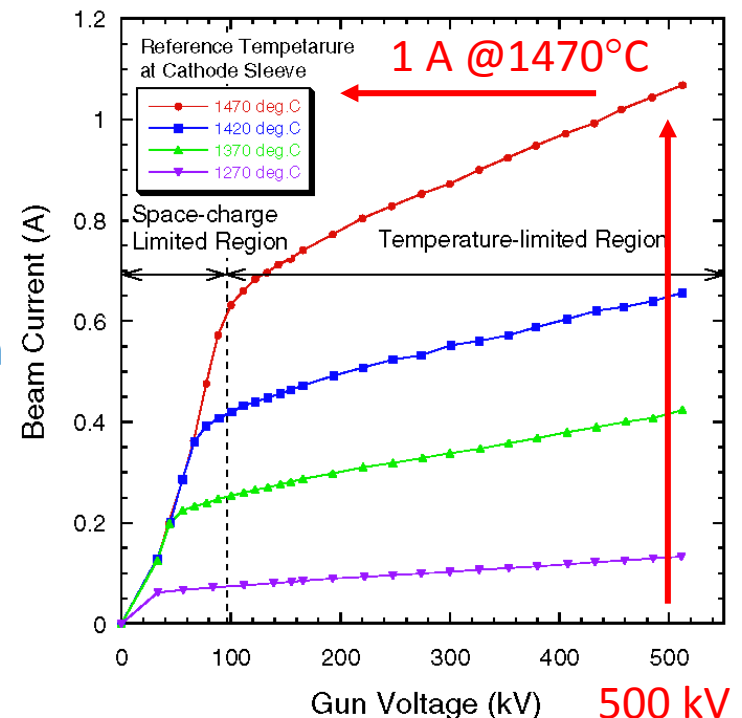
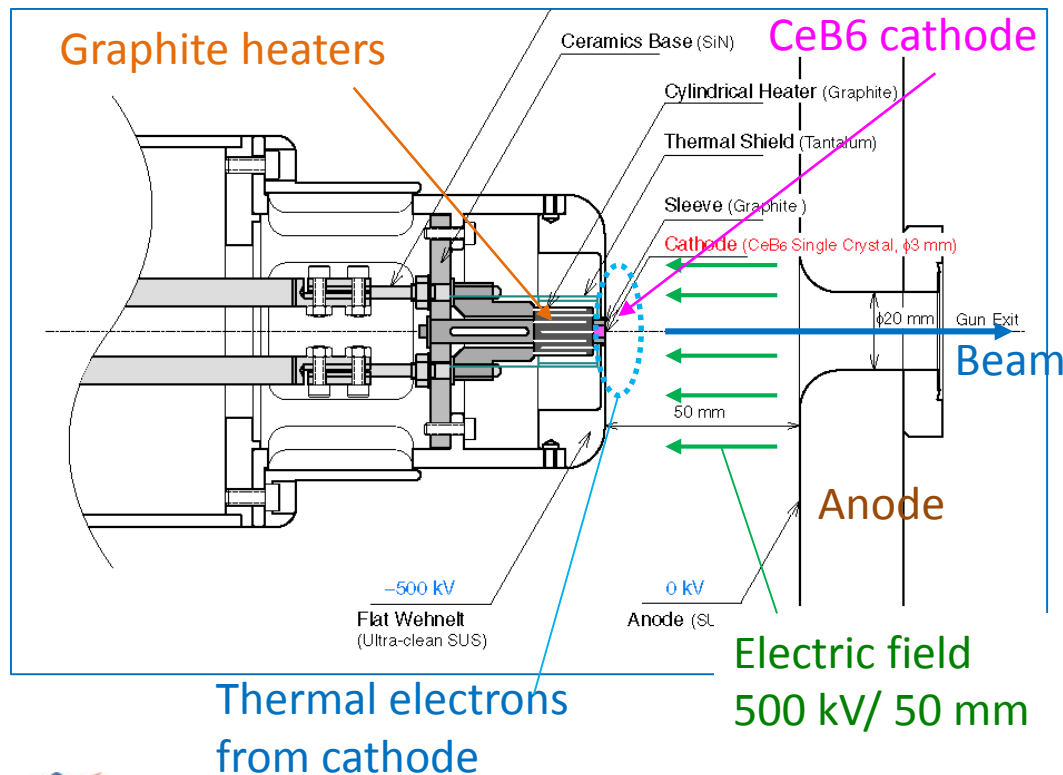
$$L_g = \frac{\lambda_u}{4\pi\sqrt{3}\rho}$$



Key technologies  
of SACLA

# Low emittance ( $\varepsilon/\gamma < 1 \pi \text{ mm}^* \text{ mrad}$ ) thermionic gun

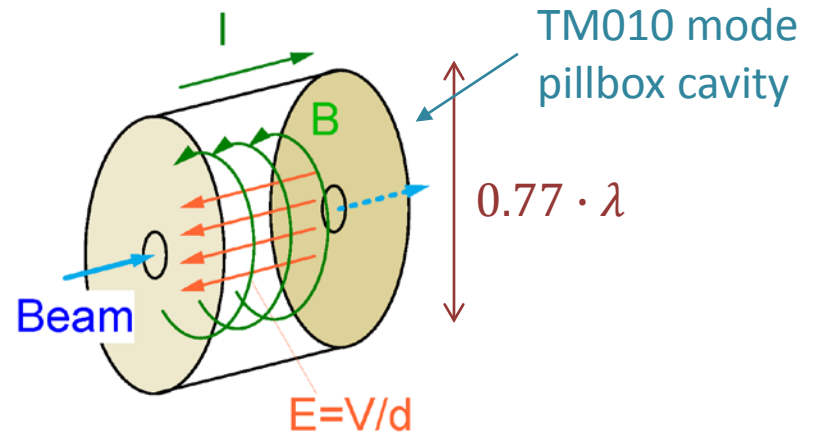
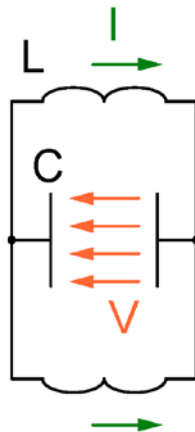
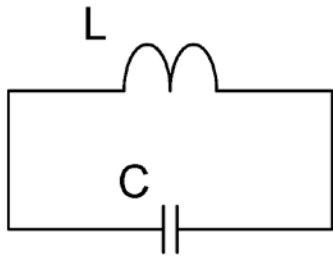
- Thermionic gun      Stable, long life, maintenance free
- CeB6 single crystal      Naturally form a flat surface
- Heated to 1500 °C      Intense e-beam ( $\sim 1 \text{ A}$ ) from 3 mm $\phi$  cathode
- 500 kV high voltage      Launch to forward direction against space charge.



# Electron accelerator consists of microwave cavities

- Microwave cavity works as a LC resonator.
- Supplying microwave power for a certain period (so called “filling time”), high electrical field is generated between the gap.
- Electron beam is accelerated with this electrical field.

Equivalent circuit



Resonant frequency:  $f = 1/(2\pi\sqrt{LC})$

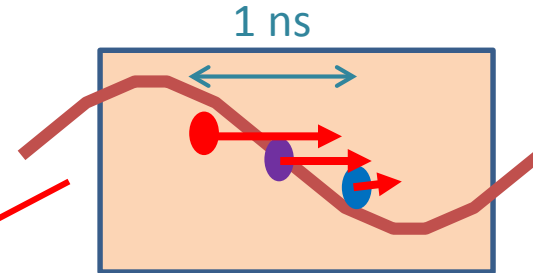
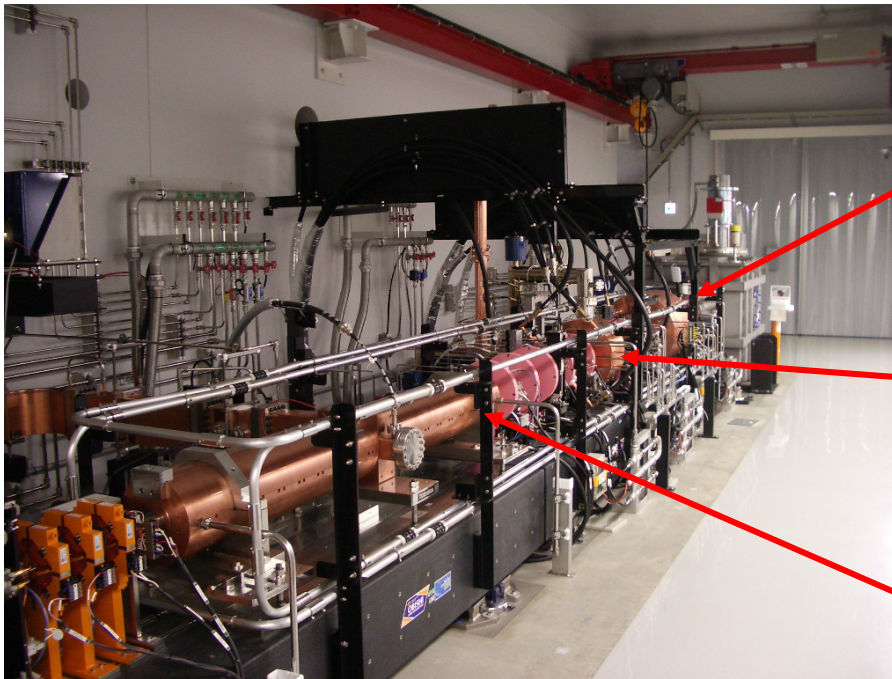
Stored energy:  $U = CV_{max}^2/2 = LI_{max}^2/2$

Acceleration voltage:

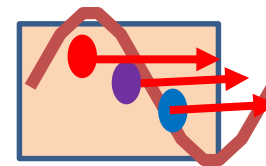
$$V_{max} = \sqrt{2U/C} = \sqrt{L/C} \cdot I_{max}$$

# Velocity bunch compression at “buncher” cavities

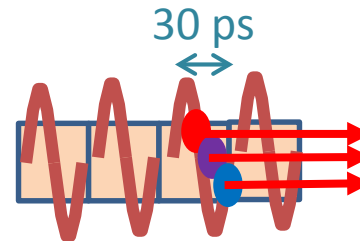
- Electron beam from the gun is accelerated at off-crest phase.
- Due to the velocity difference, electron beam is compressed.
- At the downstream, smaller cavity and higher microwave frequency are used because of the shorter bunch length.



1st cavity  
238 MHz  
( $T=4$  ns)



2nd cavity  
476 MHz  
( $T=2$  ns)



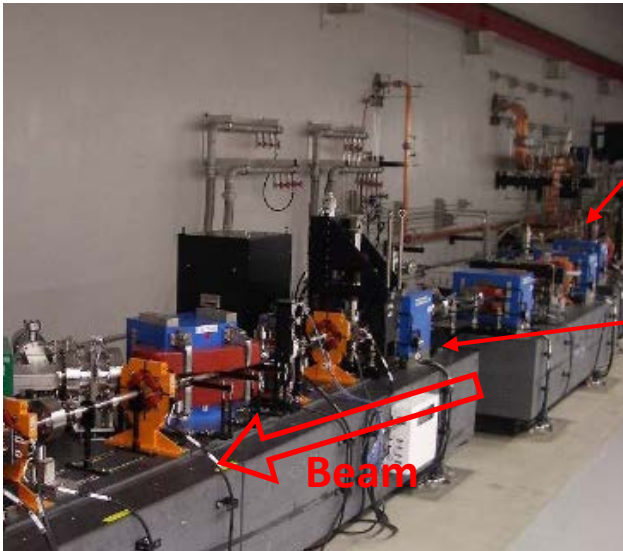
L-band accelerator  
1428 MHz  
( $T=0.7$  ns)

# Bunch compression chicane

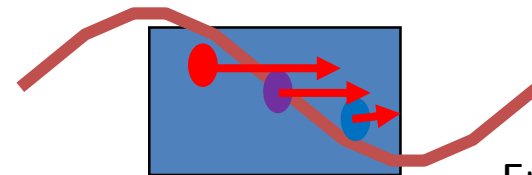
After the L-band accelerator, the bunch length is compressed using a chicane (BC1). In SACLA we use 3 stage compression (BC1, BC2, and BC3) to compress the beam to 50 fs bunch length.

These compression process is quite sensitive to the initial phase of the L-band microwave.

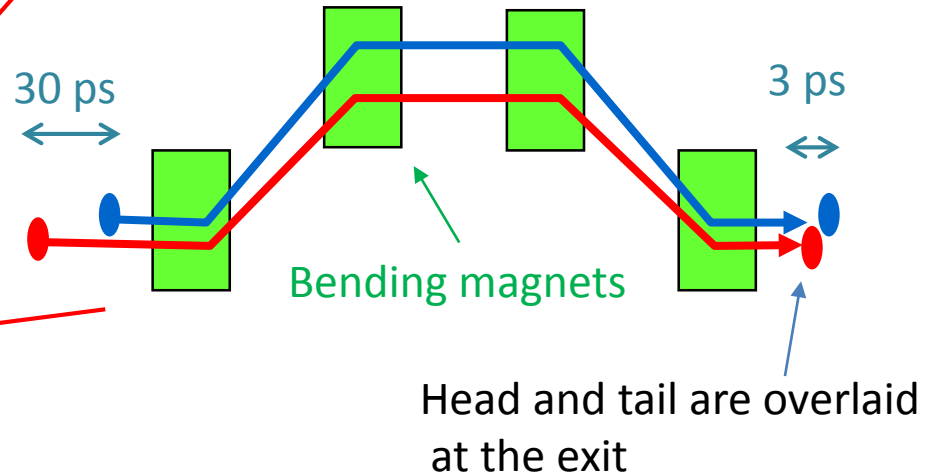
**Accuracy ~ 100 fs ( $0.05^\circ$  of 1.4 GHz)**



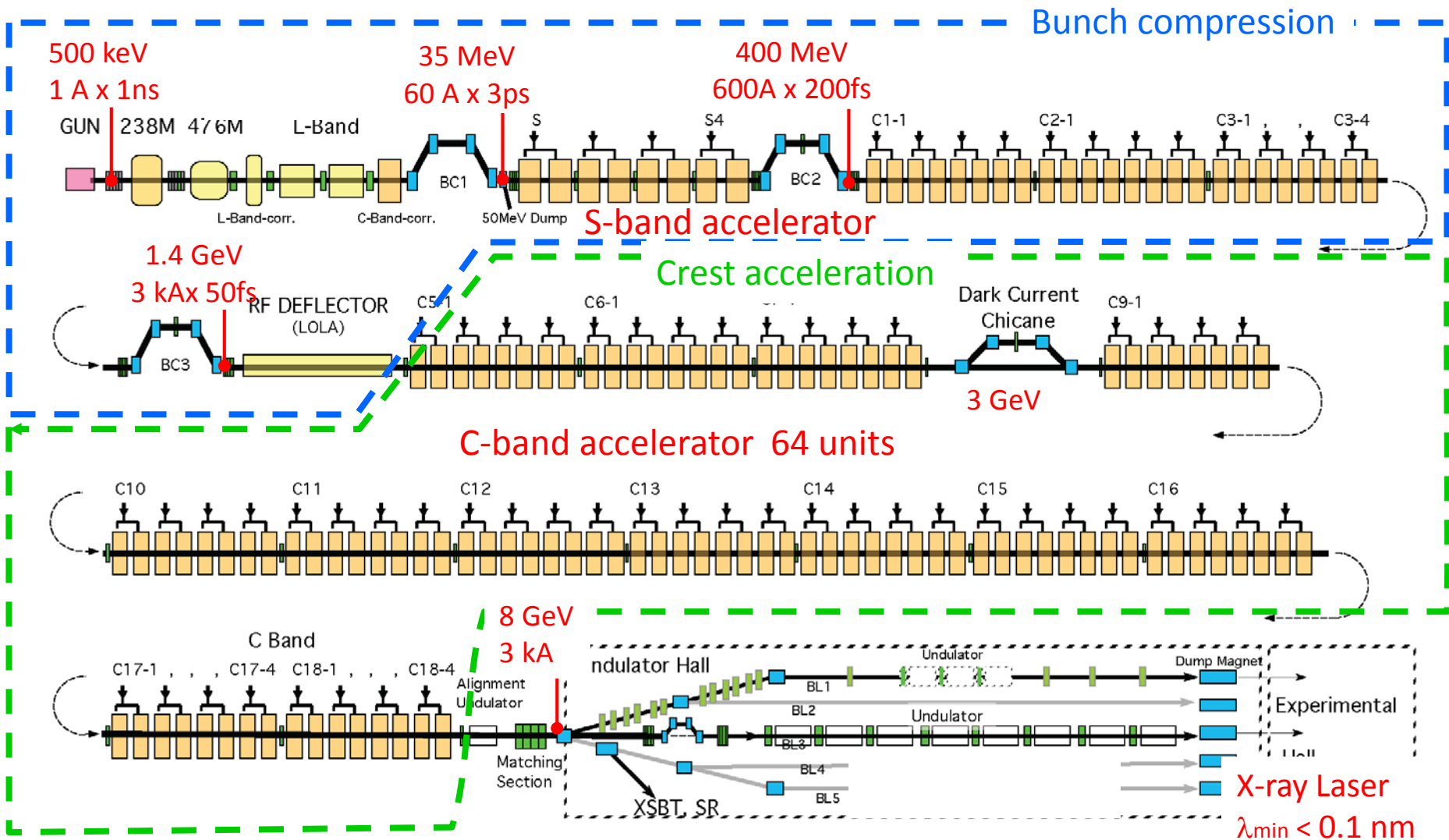
Microwave at  
L-band accelerator cavity



Energy chirp  
Head: low energy  
Tail: high energy



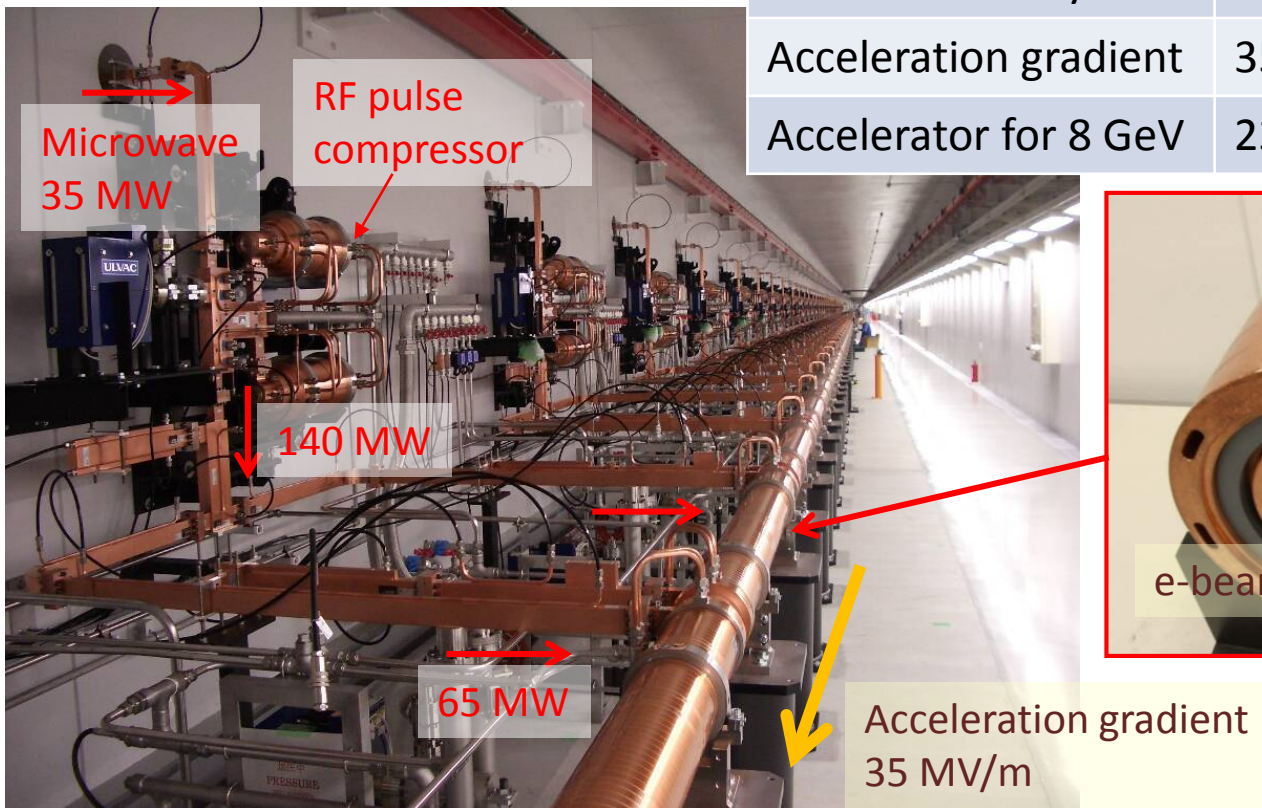
# SACLA machine configuration



# C-band (5.7 GHz) high gradient accelerator

World first accelerator to use C-band microwave frequency.  
The cavity generate twice high gradient than conventional S-band cavity, to make the facility compact.

	SACLA	Conventional
Frequency	5.7 GHz (C-band)	2.8 GHz (S-band)
Cavity size	Compact	Large
Power efficiency	Better	Worse
Acceleration gradient	35~40 MV/m	15~20 MV/m
Accelerator for 8 GeV	230 m	400 ~ 550 m



Each cavity generates 700 kV / 16 mm gap.  
Near theoretical limit of arcing at the pure copper surface.

# Klystrons (microwave source) and power supplies

## **Klystron**

50 MW microwave source

## **Pulse modulator**

350 kV pulse generation with very high precision.  
( $\Delta V/V \sim 0.001\%$ )

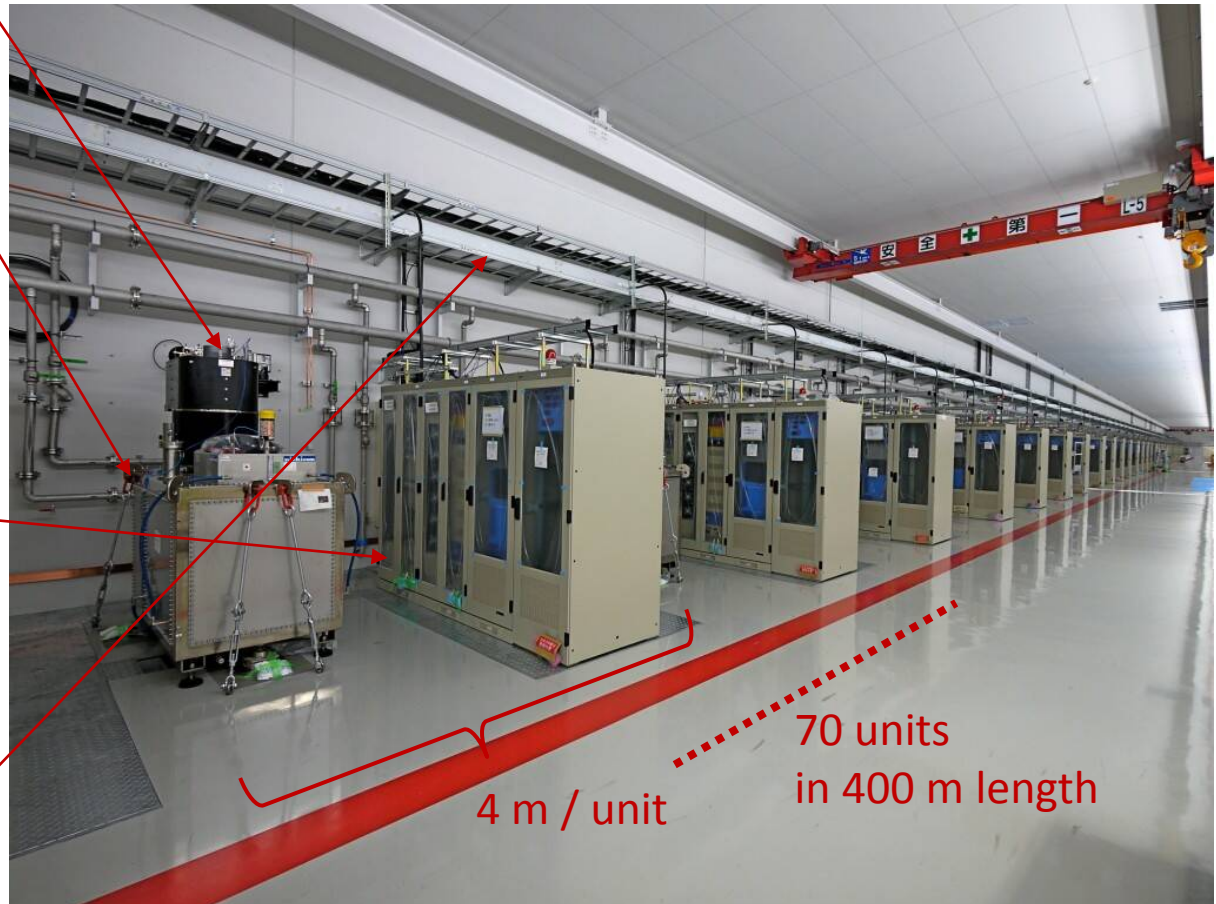
## **Control cabinet**

Microwave phase and amplitude control with  $<100$  fs and  $<0.1\%$  accuracy and stability.

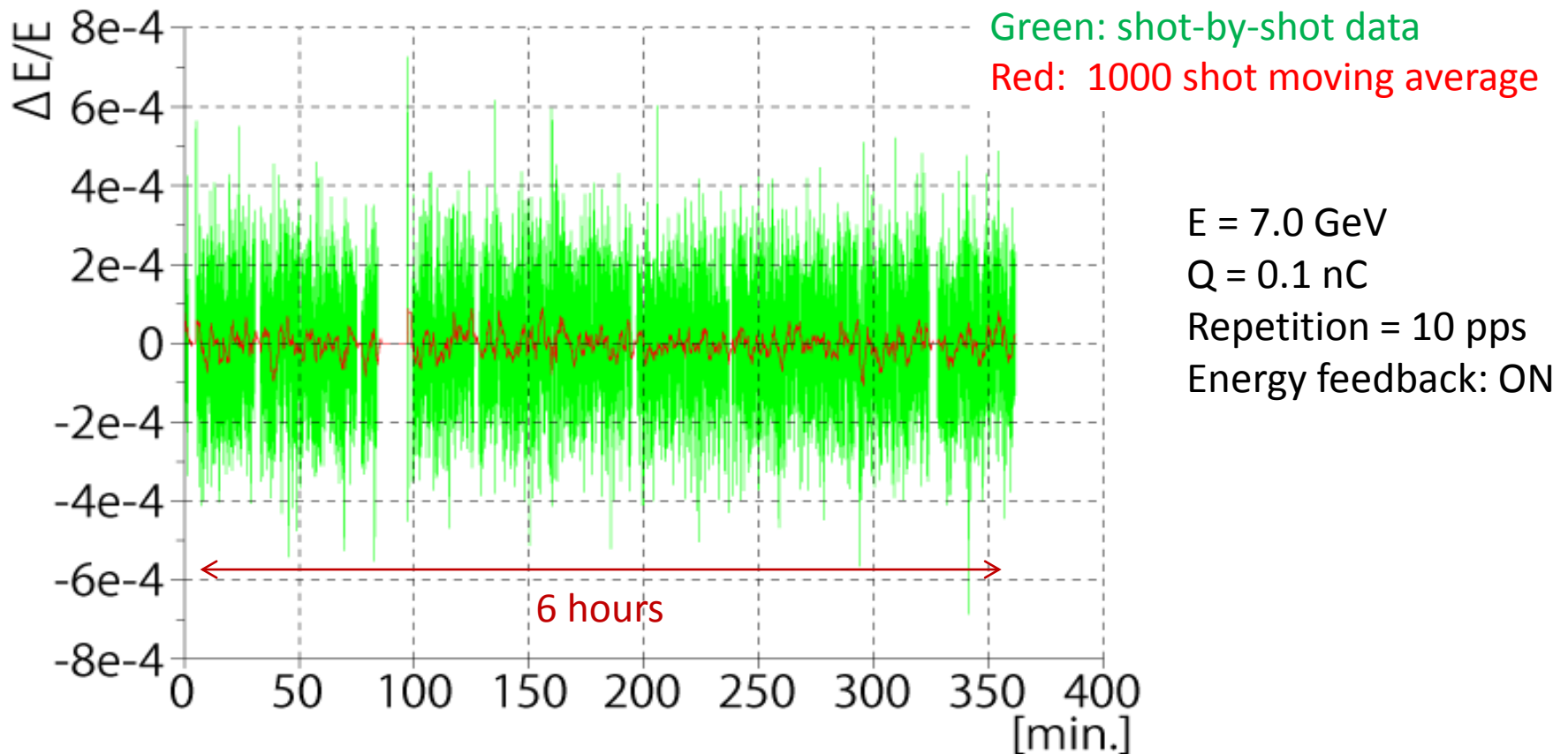
## **Timing synchronization optical fiber**

Temperature stabilized with  $<0.1$  K by a cooling water.

Supply high power microwave to the accelerator cavity with high accuracy and stability for stable SASE lasing.

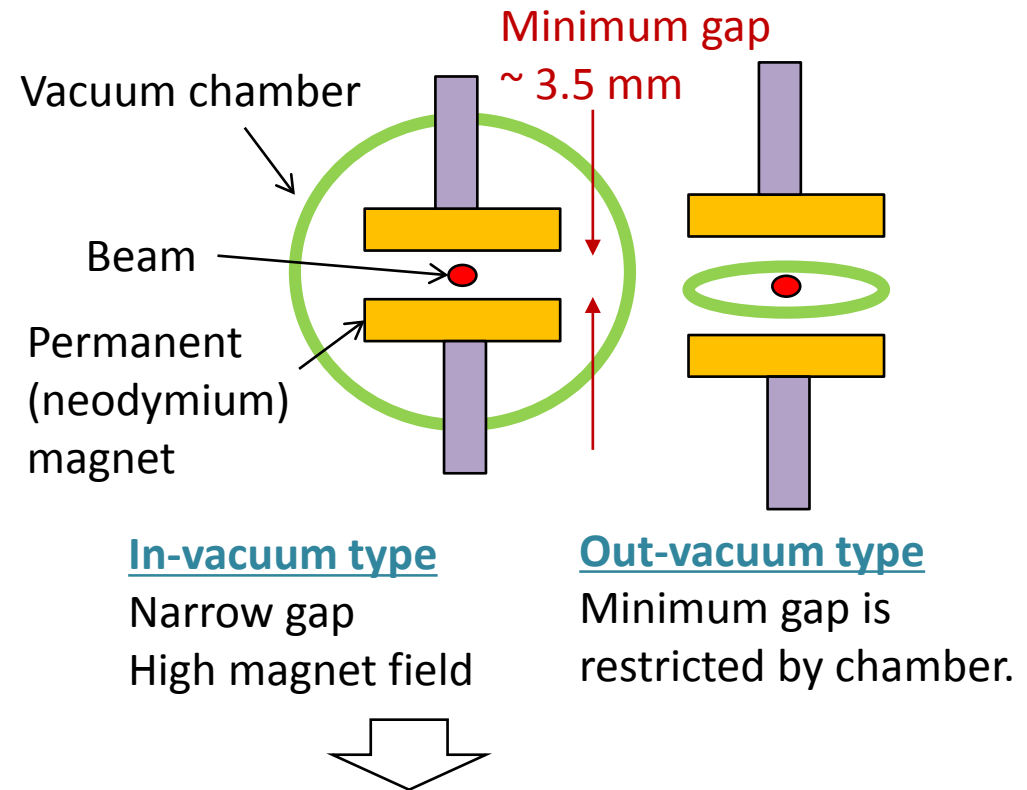
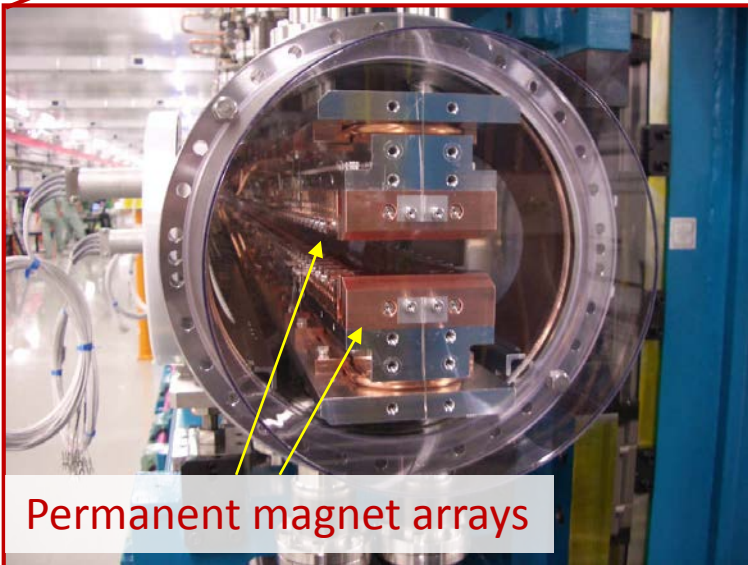
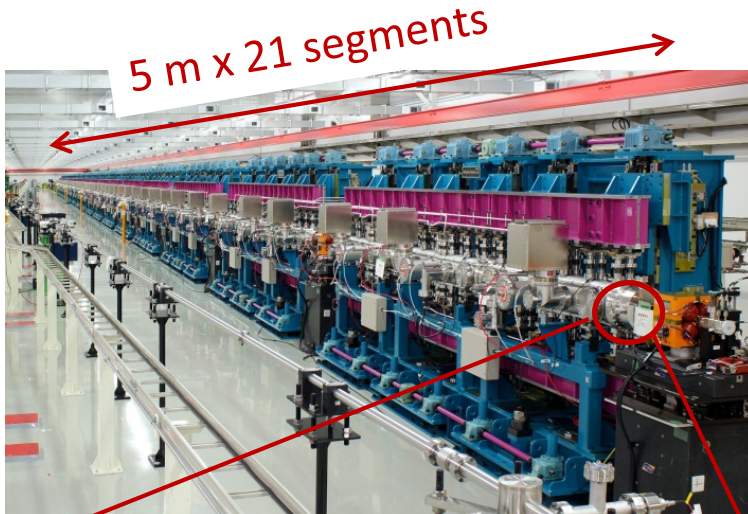


# Beam energy stability at the accelerator end



- Stability:  $1.4 \times 10^{-4}$  (rms of shot-by-shot data)
- Drift:  $< 1 \times 10^{-4}$  (100 s average)      Enough stability for SASE generation.

# In-vacuum, variable-gap undulator



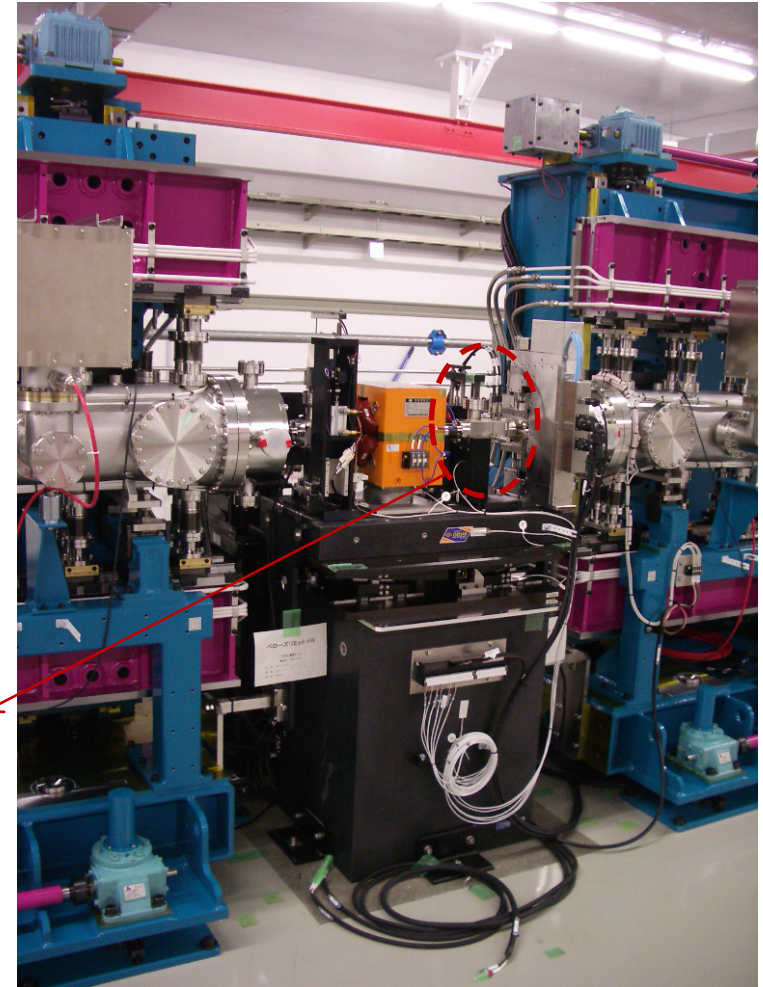
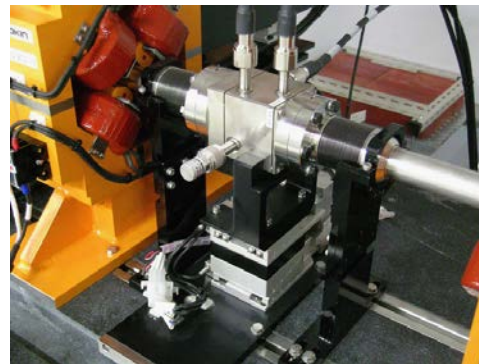
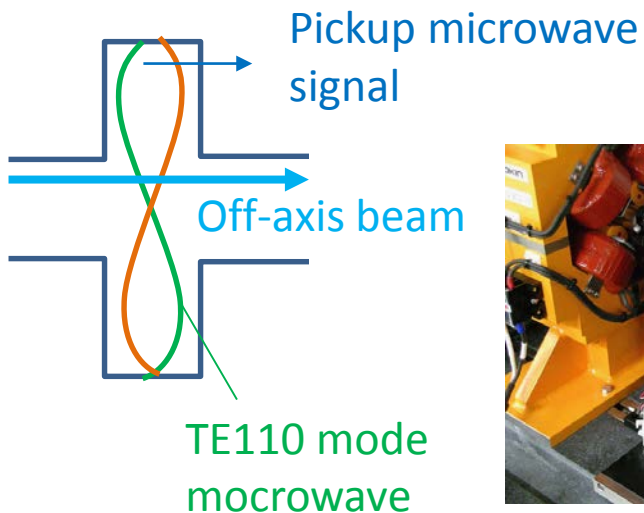
Short period  $\lambda_u = 18$  mm (half of SPring-8).  
Lower beam energy to generate X-ray.  
Short undulator length for SASE saturation.

# $\mu\text{m}$ level control of electron beam trajectory in the undulator

Electron should sufficiently overlap to SASE radiation in the undulator.

Required accuracy  $\sim$  several  $\mu\text{m}$

Cavity-type beam position monitors (BPMs) measure beam position with  $0.5 \mu\text{m}$  accuracy.



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# History of SACLA

- 2001 FEL design and development started.
- 2005 Prototype FEL machine “SCSS” construction.
- 2006 June First lasing at 49 nm.
- 2006~2010 XFEL facility “SACLA” construction.
- 2011 Feb. Beam commissioning started.
- Jun. First lasing at 0.12 nm.
- Oct. SASE power saturation achieved at 0.12 nm.
- 2012 Mar. User experiments started.
- 2013 Apr. 2-Color SASE released to user experiments.
- Nov. First experimental symptom of self-seeding observed.
- 2015 June Simultaneous operation of 2 BLs demonstrated.

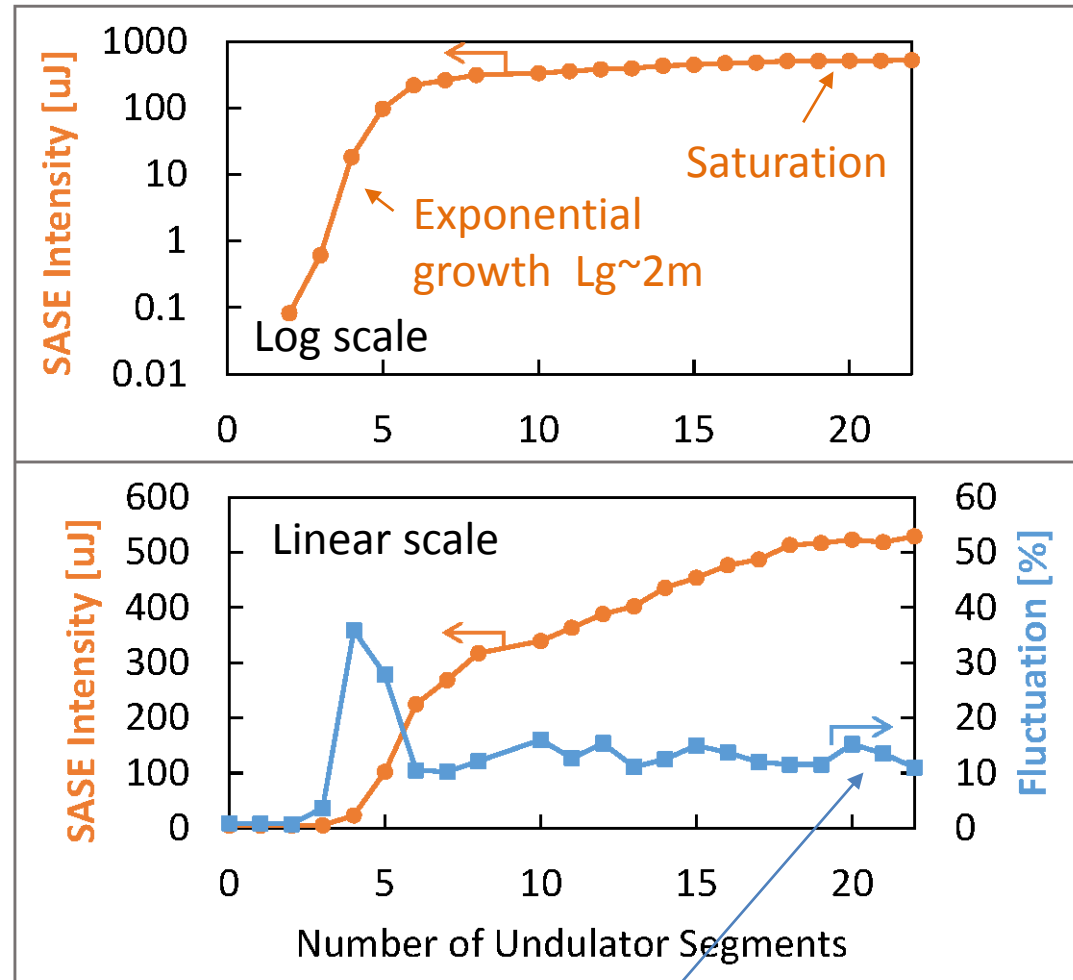
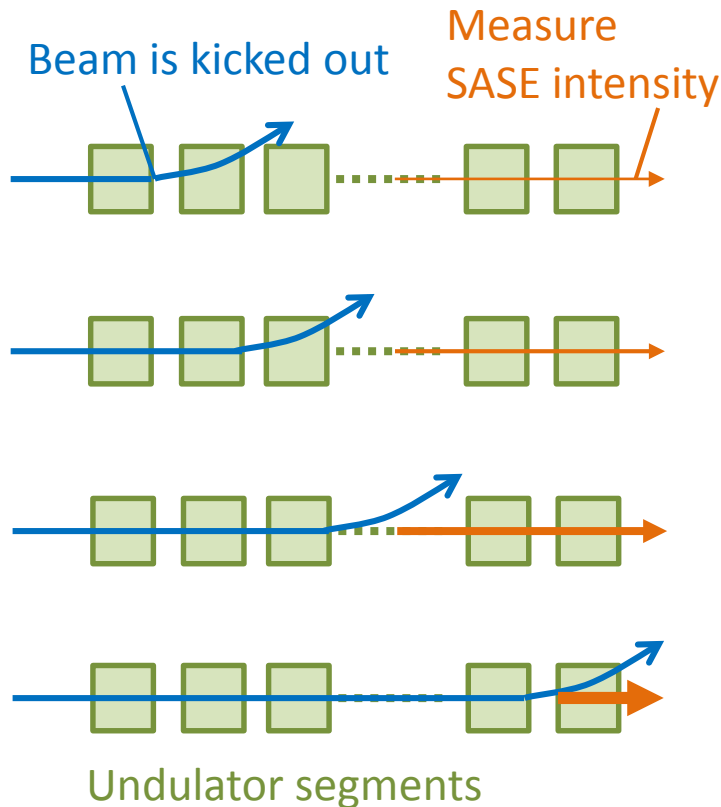


# Summary of Present XFEL Performance

Pulse Energy*:	~0.6 mJ@10keV
Peak Power*:	>60 GW (assuming 10 fs pulse)
Pulse duration*:	<10 fs
Intensity Fluctuation*:	~10% ( $\sigma$ )
Lasing Wavelength:	0.83 - 2.8 Å (user operation)
Bandwidth:	~0.5%
Spatial Coherence:	nearly full
Repetition:	30 Hz (Max.60 Hz)
Mean Fault Interval:	~50 min
Operation hour per year:	6300 hours in total 3600 hours for user operation
Laser availability rate:	93% (2014 user operation)

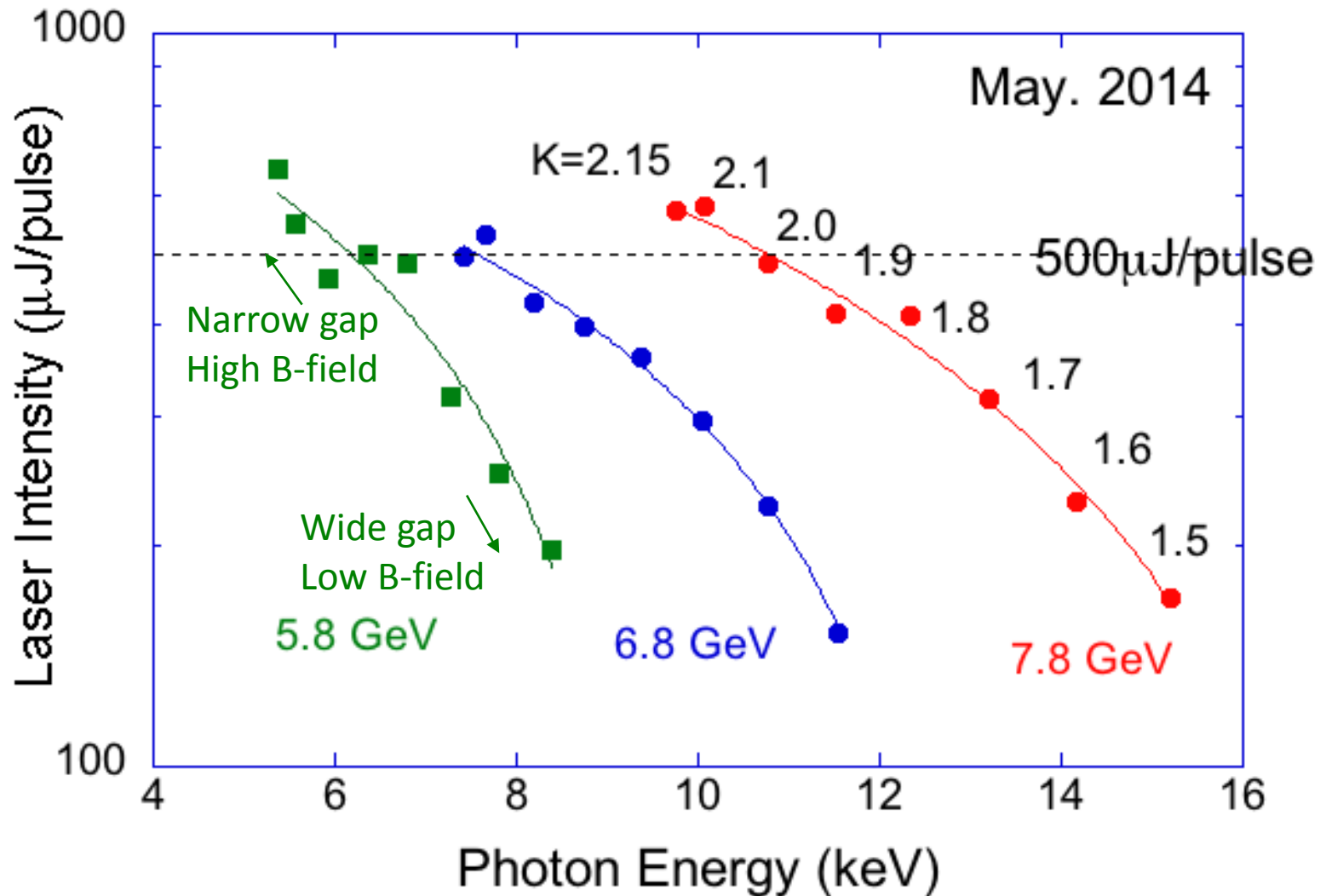
\*It depends on the condition

# SASE gain curve (July 2015, 10 keV)



Almost fundamental fluctuation of SASE lasing process (statistical fluctuation of shot noise).

# Laser Intensity vs Wavelength



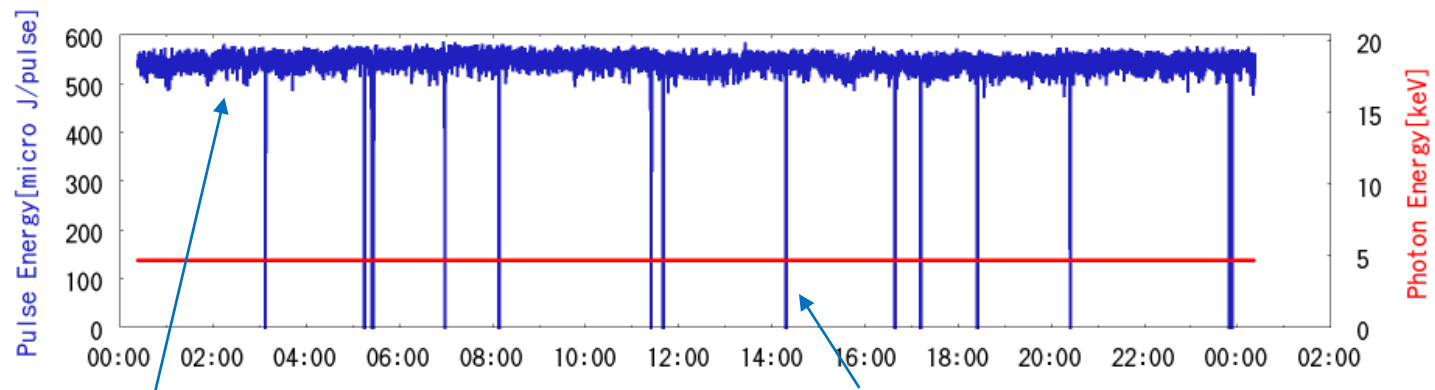
SACLA operation status is available in web: <http://sacra-status.spring8.or.jp/>

2015/7/11

## SACLA Operation Status

00:22:10

Operation Mode	
BL3 User Operation	
Hutch in Use	
BL3 EH4	
Pulse Energy	Photon Energy / Wavelength
538.8 micro J/pulse	4.7 keV / 0.264 nm
Repetition Rate	Intensity Fluctuation in 30 shots (STD)
30 Hz	8.6 %

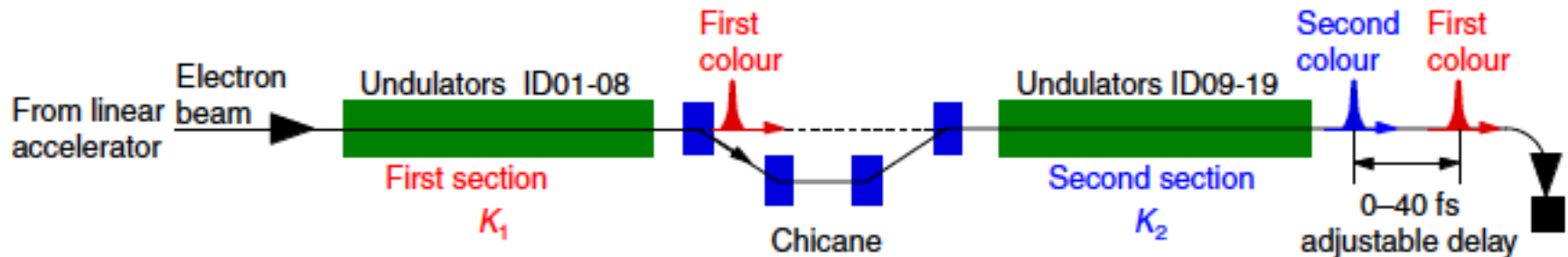
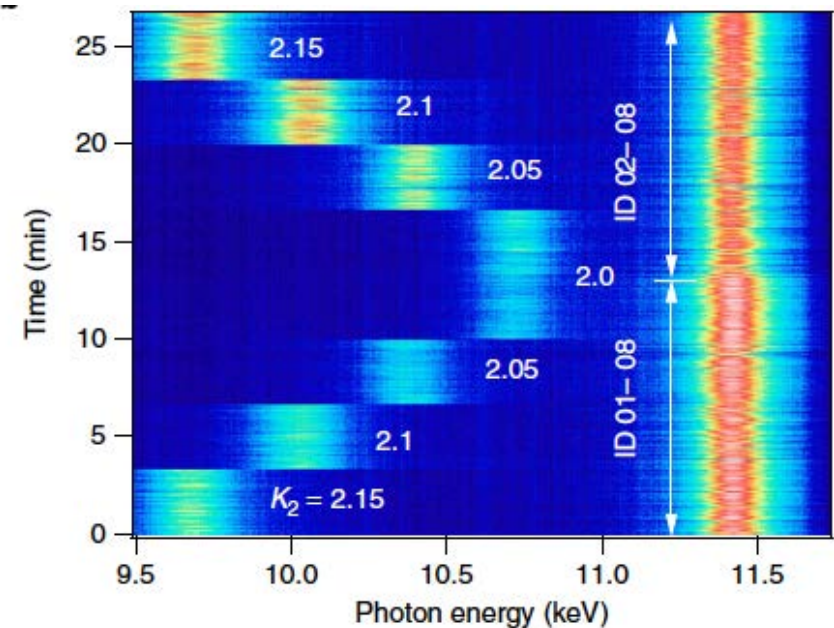
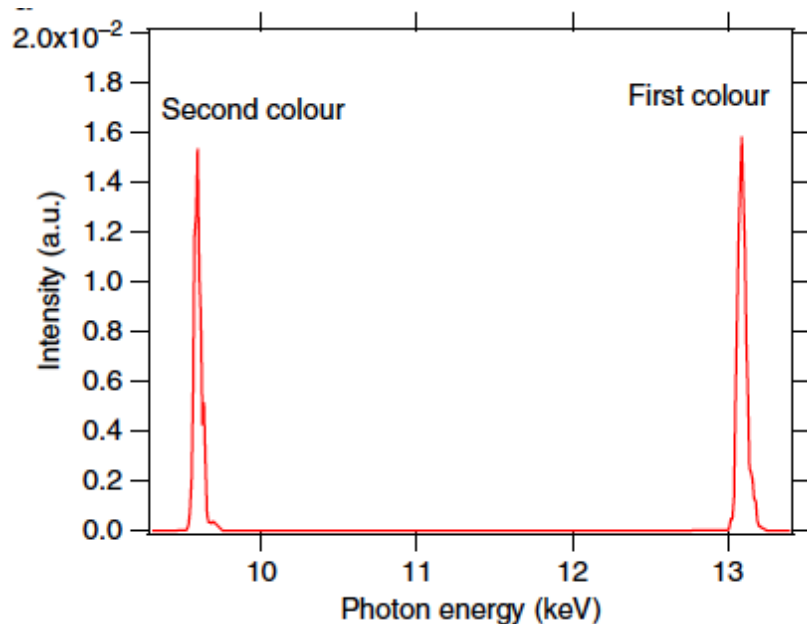


Intensity stability (24 hours)

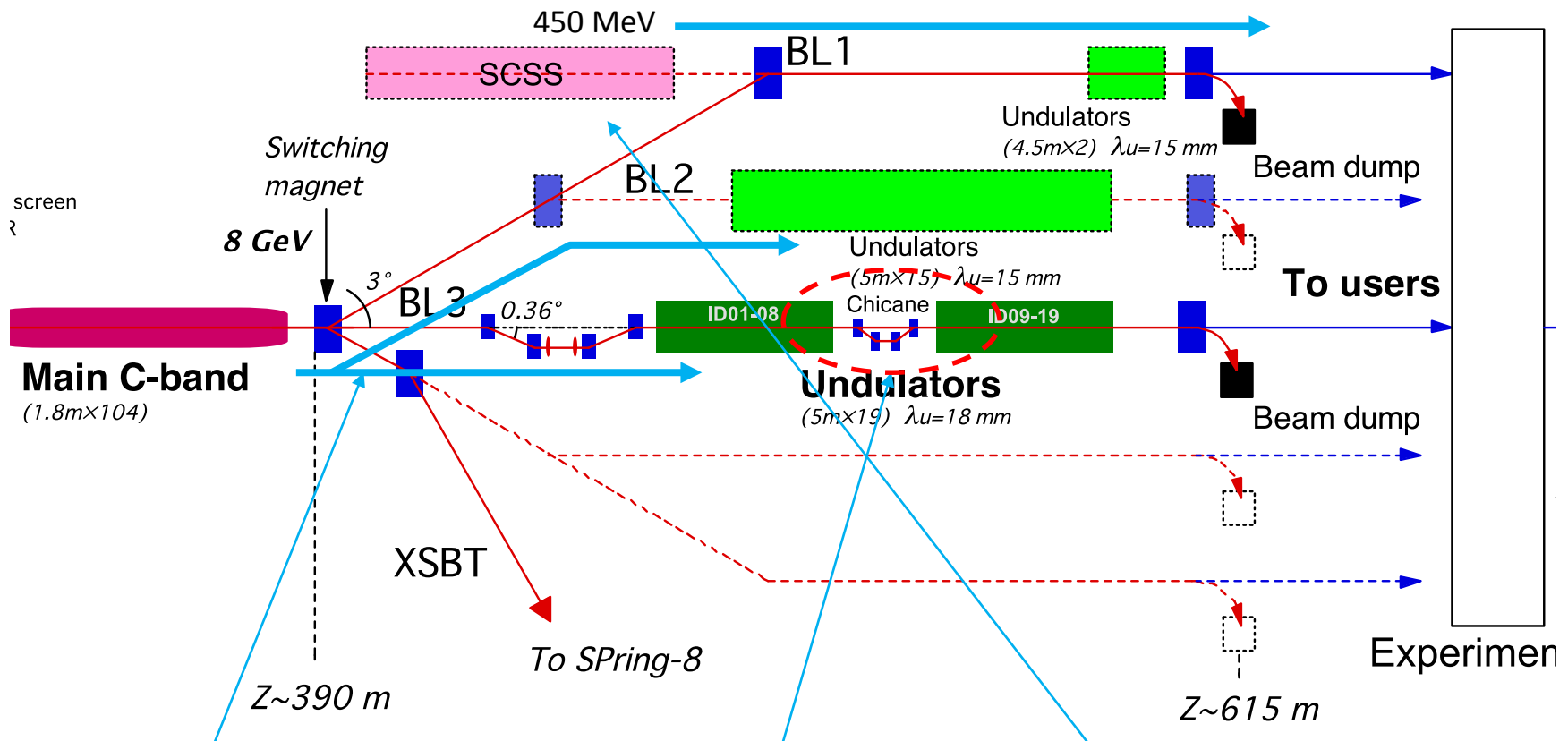
Beam interruption (accelerator fault) due to the microwave arcing and high voltage arcing.

# 2-Color SASE Routinely Available

- Wavelength separation of up to 30%
- X-ray wavelength region
- Precise delay control with an attosecond resolution



# On-going upgrade plans



**More user experiments.**  
Multi-beamline operation  
with fast switching magnet.

**Monochromatic XFEL**  
Self-seeding using  
diamond crystal.

**EUV ~ Soft X-ray FEL**  
Dedicated accelerator  
has been constructed.

# Summary

- X-ray free electron laser (XFEL)
  - Only way to generate laser in X-ray wavelength region.
  - Extremely high brilliant, ultra-short, and spatially full coherent X-ray pulse.
  - Following the two XFEL facilities LCLS and SACLA, several XFEL projects at PAL, PSI, Shanghai, and European-XFEL are under construction.
- SACLA
  - Compact and low construction cost, but high performance XFEL facility.
  - Based on 3 key technologies; a low emittance thermionic gun, high gradient C-band linear accelerators, and short period in-vacuum undulators.
  - Since 2012, SACLA has successfully provided X-ray laser for various user experiments, without any serious troubles.

# Thank you

